

Notice of References Cited	Application/Control No. 10/826,564	Applicant(s)/Patent Under Reexamination ENGBRECHT ET AL.	
	Examiner Tu-Tu Ho	Art Unit 2818	Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	A	US-4,868,093	09-1989	Levy, Roland A.	430/311
	B	US-			
	C	US-			
	D	US-			
	E	US-			
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	I	US-			
	J	US-			
	K	US-			
	L	US-			
	M	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
	N					
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NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
	U	Ekerdt et al., Design, growth and Properties of Boron Carbonitride Insulating diffusion Barriers for Nanosized Electronic Devices
	V	Kosinova et al., Chemical Composition of Boron Carbonitride Films Grown by Plasma-Enhanced Chemical Vapor Deposition from Trimethylamine borane, 2003, Inorganic Materials, pp 366-373.
	W	
	X	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)
Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.